



PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No.: 10/706,861 Confirmation No.: 6729  
Applicant(s): Hamada et al.  
Filed: 11/12/2003  
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND  
METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM, AND  
SEMICONDUCTOR DEVICE

Docket No.: 035576/271444  
Customer No.: 00826

June 25, 2004

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT  
37 CFR § 1.115**

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims beginning on page 2 of this paper.

**Remarks** begin on page 5 of this paper.